

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|-----------------------|---|--|--------------------|-------------|-------------------------|
| Serial No. | : | 10/526,383 | Confirmation No. : | 3829 | |
| Filing Date | : | 13 September 2005 | Art Unit | : | 1752 |
| First Named Inventor: | | Nobuji Sakai | Examiner | : | Cynthia Hamilton |
| Customer No. | : | 54884 | Docket No. | : | Toyo-3 |
| Title: | : | Radiation-Sensitive Negative-Type Resist Composition for Pattern Formation and Pattern Formation Method | | | |

AMENDMENT AND RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir or Madam:

This Amendment is in response to the Office Action dated 21 March 2007.

Amendments to the claims begin on page 2.

Remarks begin on page 5.

Please amend the above-identified application without prejudice or disclaimer of subject matter as follows: